

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Sherman
App. No	:	10/692,243
Filed	:	October 22, 2003
For	:	SEQUENTIAL CHEMICAL VAPOR DEPOSITION
Examiner	:	David P. Turocy
Art Unit	:	1792

**COMMENTS ON STATEMENT OF REASONS FOR ALLOWANCE**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

This communication is submitted in response to the Notice of Allowance dated April 28, 2008. In discussing the reasons for allowance, the Examiner refers generally to the lack of certain teachings in the prior art of record. Applicant does not necessarily agree with the Examiner's characterization of the prior art and respectfully disagrees with the Examiner's reasons for allowance to the extent there is any implication that the patentability of the claims rests on the recitation of a single feature or group of features. Each of the allowed claims recites different combinations of features and elements and it is each claim taken as a whole that is patentable. Thus, to the extent that the Examiner's paraphrasing of the subject matter of particular independent claims differs from the language of the allowed claims, Applicant respectfully disagrees with the Examiner's reasons for allowance.

In summarizing the substance of the interview of 14 April 2008, the Examiner states that Applicant agrees "to cancel Claims 8-11 in order to place the application in condition for allowance." Applicant continues to believe that Claims 8-11 are allowable, and Claims 8-11 have been cancelled only to expedite prosecution and allowance of Claims 1-7.

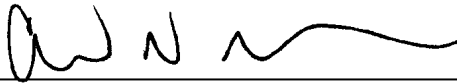
Docket No.: ASMMC.9CP1DV1D  
App. No.: 10/692,243

June 12, 2008  
Page 2 of 2

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: July 3, 2008

By: 

Andrew N. Merickel  
Registration No. 53,317  
Attorney of Record  
Customer No. 20,995  
(415) 954-4114

5038305  
031908